

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Yasuyo SAITO, et al.

SERIAL NO: NEW APPLICATION

GAU:

FILED: HEREWITH

EXAMINER:

FOR: ORGANIC METAL COMPLEX, INFRARED-ABSORBING DYE AND INFRARED ABSORPTION FILTER CONTAINING IT, AND FILTER FOR PLASMA DISPLAY PANEL



INFORMATION DISCLOSURE STATEMENT UNDER 37 CFR 1.97

ASSISTANT COMMISSIONER FOR PATENTS
WASHINGTON, D.C. 20231

SIR:

Applicant(s) wish to disclose the following information.

REFERENCES

- ☒ The applicant(s) wish to make of record the references listed on the attached form PTO-1449. Copies of the listed references are attached, where required, as are either statements of relevancy or any readily available English translations of pertinent portions of any non-English language references.
- ☐ A check is attached in the amount required under 37 CFR §1.17(p).

RELATED CASES

- ☐ Attached is a list of applicant's pending application(s) or issued patent(s) which may be related to the present application. A copy of the patent(s), together with a copy of the claims and drawings of the pending application(s) is attached along with PTO 1449.
- ☐ A check is attached in the amount required under 37 CFR §1.17(p).

CERTIFICATION

- ☐ Each item of information contained in this information disclosure statement was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of this statement.
- ☐ No item of information contained in this information disclosure statement was cited in a communication from a foreign patent office in a counterpart foreign application or, to the knowledge of the undersigned, having made reasonable inquiry, was known to any individual designated in 37 CFR §1.56(c) more than three months prior to the filing of this statement.

DEPOSIT ACCOUNT

- ☒ Please charge any additional fees for the papers being filed herewith and for which no check is enclosed herewith, or credit any overpayment to deposit account number 15-0030. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

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Form PTO 1449
(Modified)U.S. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICE

ATTY DOCKET NO.

217830US0CONT

SERIAL NO.

NEW APPLICATION

LIST OF REFERENCES CITED BY APPLICANT

APPLICANT

Yasuyo SAITO, et al.

FILING DATE

HEREWITH

GROUP

 J0625 U.S. PAT.
 10/046108
 01/17/92

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
	AA	5,804,102	09/08/98	OI ET AL			
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						
	AL						
	AM						
	AN						

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	TRANSLATION	
					YES	NO
	AO	63-112592	05/17/88	JAPAN		XX
	AP	4-174402	06/22/92	JAPAN		XX
	AQ	6-38124	05/18/94	JAPAN		XX
	AR	2-4881	01/30/90	JAPAN		XX
	AS					
	AT					
	AU					
	AV					

OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, etc.)

	AW	T. KAWAMOTO ET AL, "CARBON-CARBON BOND FORMTION IN HELICAL NICKEL (II) COMPLEX, CIS-BIS [2-N-(PHENYLMETHYLIDENEAMINE) BENZENETHIOLATO] NICKEL (II)", CHEMISTRY LETTERS, 1992, NO. 5, PP. 893-896				
	AX	T. KAWAMOTO ET AL, "VALENCE ISOMERIZATION. SYNTHESIS AND CHARACTERIZATION OF COBALT AND NICKEL COMPLEXES WITH NON-INNOCENT N2S2 LIGAND", BULL. CHEM. SOC. JPN., 1997, VOL. 70, NO. 7, PP. 1599-1606				
	AY	T. KAWAMOTO ET AL, "SYNTHESIS AND CHARACTERIZATION OF THE PLATINUM COMPLEXES WITH N,S OR C,N,S LIGANDS DERIVED FROM 2-PHENYLBENZOTHAZOLINE", INORG. CHIM. ACTA, 1997, VOL. 265, NO. 1-2, PP. 163-167				
	AZ					<input type="checkbox"/> Additional References sheet(s) attached

Examiner

Date Considered

*Examiner: Initial if reference is considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.